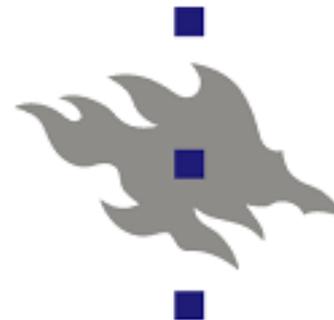


Uniting physics, biology and medicine for better healthcare



Metal implanted multi-functional nanovectors for targeted radiotherapy and diagnostics of cancer

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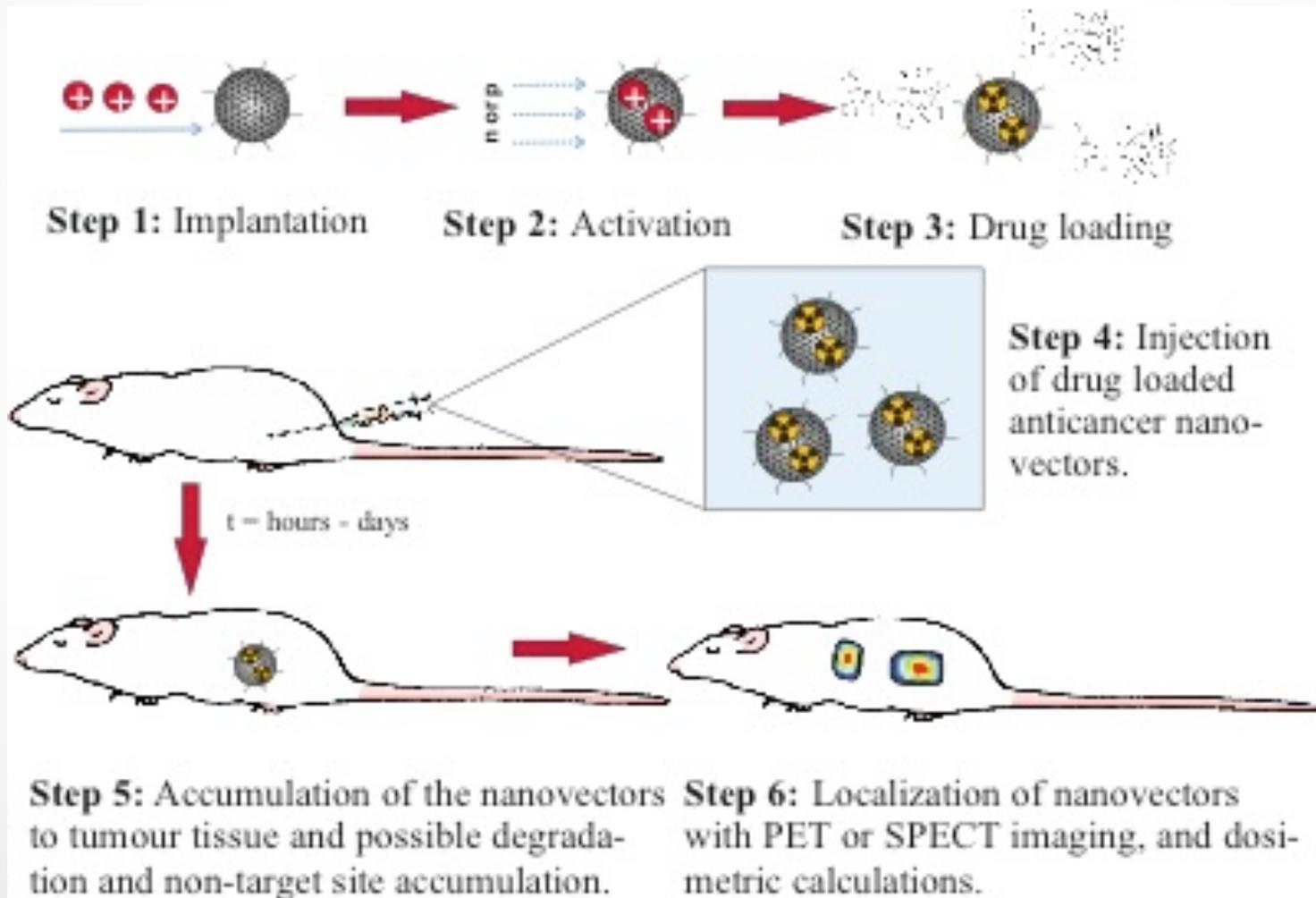
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Outline

- Principle
- Results on activation experiment
- Results on direct implantation experiment
- Conclusion

Principle

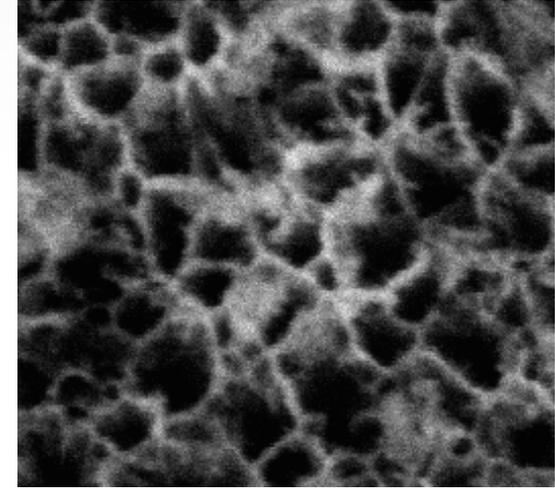
- Radionuclide + mesoporous silicon nanoparticles → targeted radiotherapy



Principle (2) – PSi nanoparticles

Properties of mesoporous silicon

- biocompatible & biodegradable
- Silicon lattice is amenable for ion implantation
- High temperature resistance
- High adsorption capacity with anti-cancer drug



Particles fabrication

- For activation: The particles have been deposited with copper using electroless deposition technique followed by thermal annealing and carbonization – processed to nanosize particles by pulse-etching
- For direct implantation: sonication of wafers in EtOH in a minigrip bag for several hours



Principle (3) – Radionuclide

- All the selected nuclides have a therapeutic application, either by utilising β^- particles or Auger/conversion electrons. All nuclides have also emissions that can be utilised in PET (^{64}Cu) or SPECT (^{169}Yb).

Nuclide	$T_{1/2}$	Main emissions	Production	Application
^{64}Cu	12.7 h	e^- , $E=6.6$ keV, $I_e=22.5\%$ β^+ , $E_{\text{max}}=653$ keV, $I_\beta=17.6\%$ β^- , $E_{\text{max}}=579$ keV, $I_\beta=38.5\%$	$^{63}\text{Cu}(n,\gamma)$, $^{64}\text{Ni}(p,n)$	Imaging (PET, autoradiography) Therapeutic
^{169}Yb	32.0 d	e^- , $E=5.7$ keV, $I_e=161.8\%$ e^- , $E=6.1$ keV, $I_e=74.8\%$ e^- , $E=7.9$ keV, $I_e=17.3\%$ e^- , $E=41$ keV, $I_e=10.6\%$ e^- , $E=50$ keV, $I_e=34.3\%$ e^- , $E=118$ keV, $I_e=10.9\%$ e^- , $E=139$ keV, $I_e=12.9\%$ X-ray, $E=50$ keV, $I_\gamma=52.5\%$ X-ray, $E=51$ keV, $I_\gamma=91.6\%$ X-ray, $E=58$ keV, $I_\gamma=19.0\%$ γ , $E=63$ keV, $I_\gamma=43.6\%$ γ , $E=110$ keV, $I_\gamma=17.4\%$ γ , $E=131$ keV, $I_\gamma=11.4\%$ γ , $E=177$ keV, $I_\gamma=22.3\%$ γ , $E=198$ keV, $I_\gamma=35.9\%$ γ , $E=308$ keV, $I_\gamma=10.1\%$	Direct production, $^{168}\text{Yb}(n,\gamma)$, $^{169}\text{Tm}(p,n)$	Imaging (SPECT, autoradiography) Therapeutic Dissolution studies

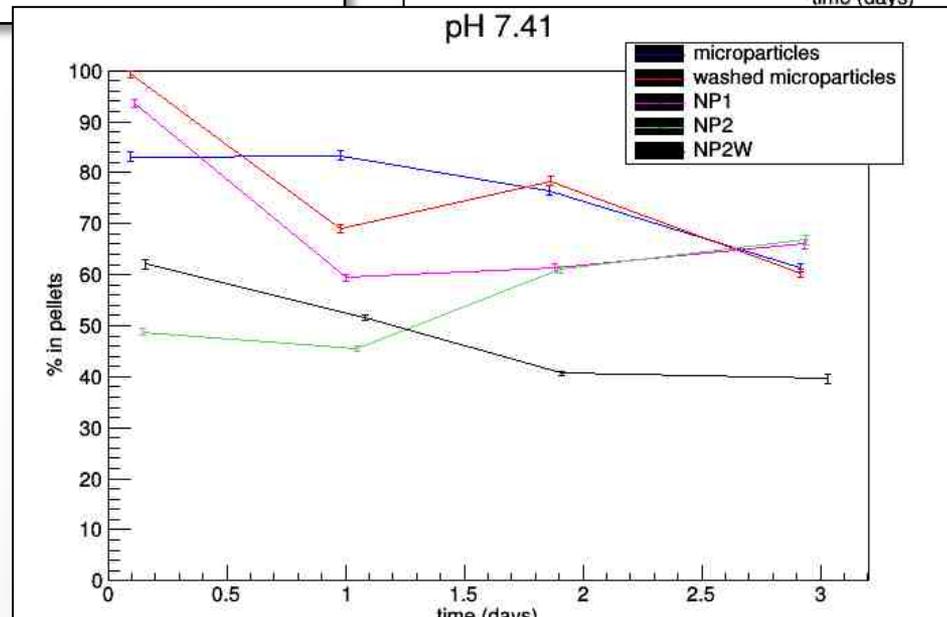
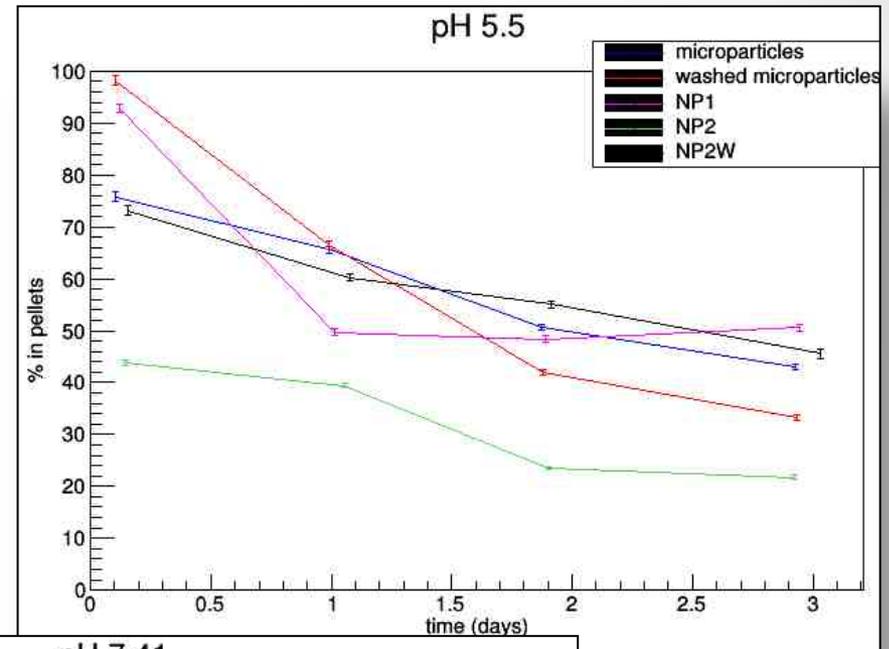
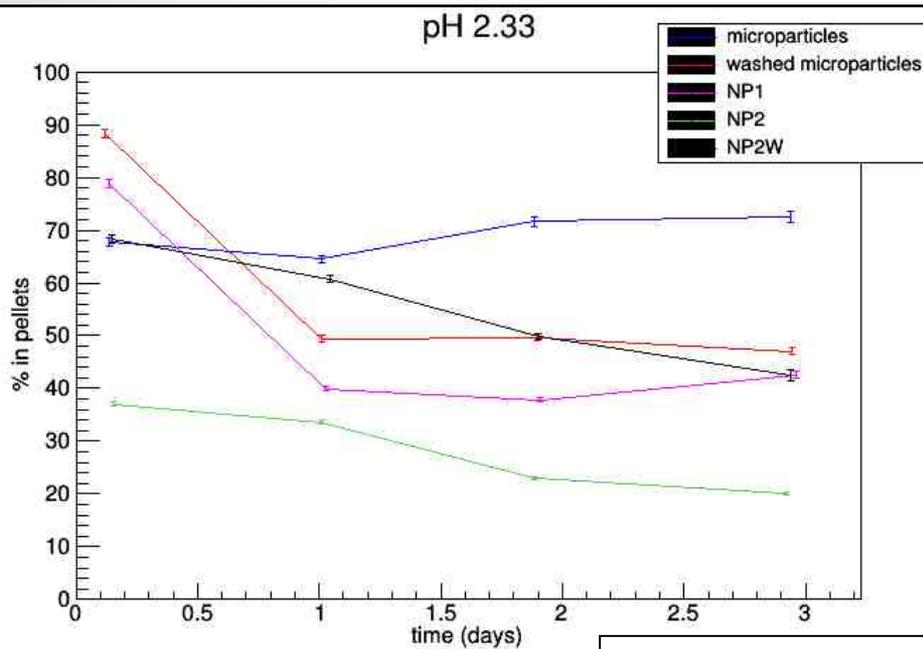
Activation experiment: Cu-deposited PSi

- Samples preparation at University of Turku (Finland) – nanoparticles and microparticles
- Neutronic-activation in FiR-1 research reactor at Technical Research Centre of Finland (VTT) ($\phi_n \approx 5e12 \text{ cm}^{-2} \cdot \text{s}^{-1}$)
 - 3h irradiation
 - Radioactive element ^{64}Cu ($T_{1/2} = 12.7 \text{ h}$)

Sample	Size	Treatment	Activity (MBq)
NP1	160-170 nm	600°C annealed + native oxidation	0.920
NP2	160-170 nm	600°C annealed + thermal hydrocarbonization (THC) treatment	0,890
NP2W	160-170 nm	600°C annealed + THC treatment + HCl washing	0,440
S2	25-53 μm	600°C annealed + THC treatment	0,699
S2W	25-53 μm	600°C annealed + THC treatment + HCl washing	0,353

Dissolution/stability studies

10 mM phosphate buffers with different pH



- microparticles
- washed microparticles
- NP1
- NP2
- washed NP2

Concentration 0.025mg/mL

Direct implantation with radioactive beam

^{169}Yb Direct implantation in P Si @ CERN

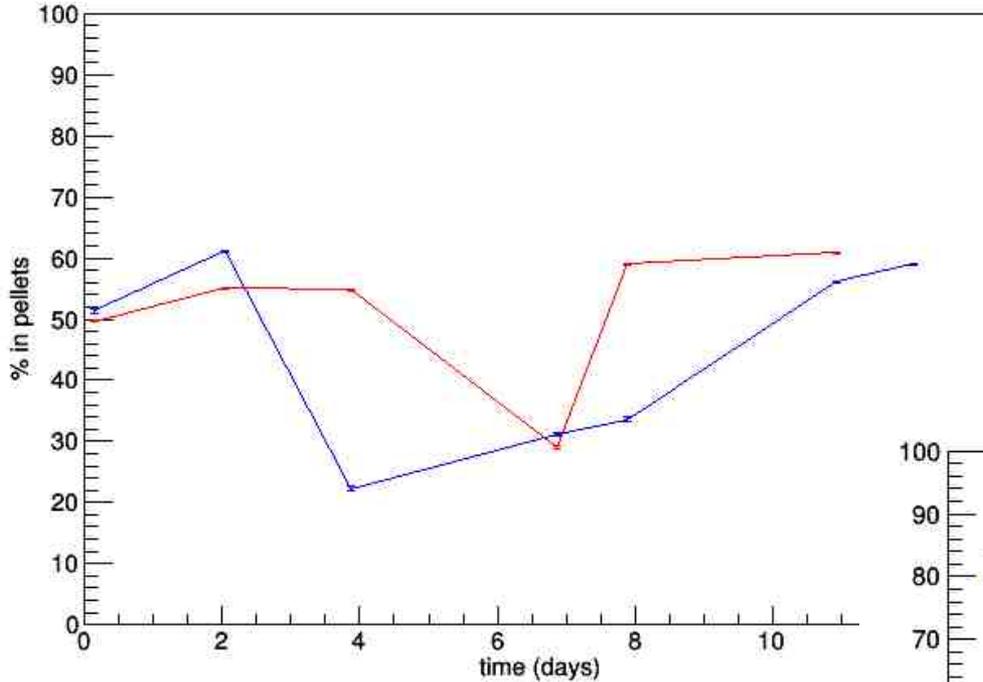
- Two silicon wafers (one fresh and one oxidized) were implanted at CERN (11/08/2015)
- Total activity (for the two wafers) measured by collaborators:
 - $^{169}\text{Yb} \approx 2 \text{ MBq}$
 - $^{169}\text{Lu} \approx 1 \text{ MBq}$
 - $^{153}\text{Tb} \approx 6 \text{ MBq}$ as a molecular sideband
- Total activity on 31/08/2015
 - Fresh wafer
 - $^{169}\text{Yb} = 0,6642(4) \text{ MBq}$
 - $^{153}\text{Gd} = 0,1452(5) \text{ MBq}$
 - $^{153}\text{Tb} = 0,0065(1) \text{ MBq}$
 - Oxidized wafer
 - $^{169}\text{Yb} = 0,5385(5) \text{ MBq}$
 - $^{153}\text{Gd} = 0,0816(5) \text{ MBq}$
 - $^{153}\text{Tb} = 0,0052(1) \text{ MBq}$

^{169}Yb

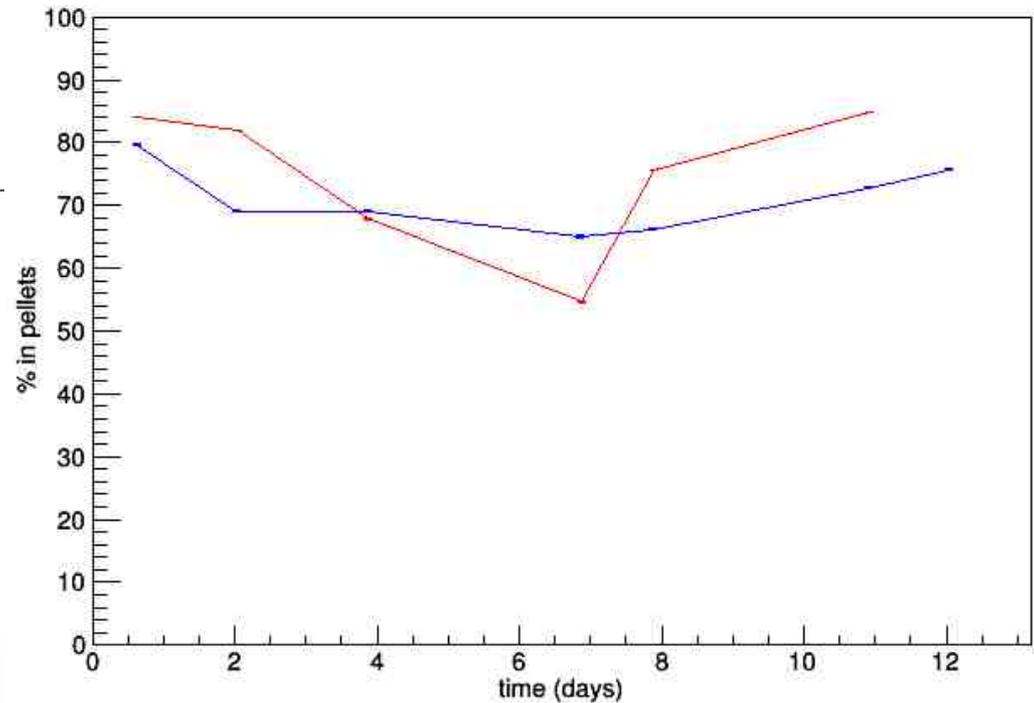
Dissolution studies: results

10 mM phosphate buffers with pH 2.33 & 5.5

ph 2.33



ph 5.5



-- Fresh

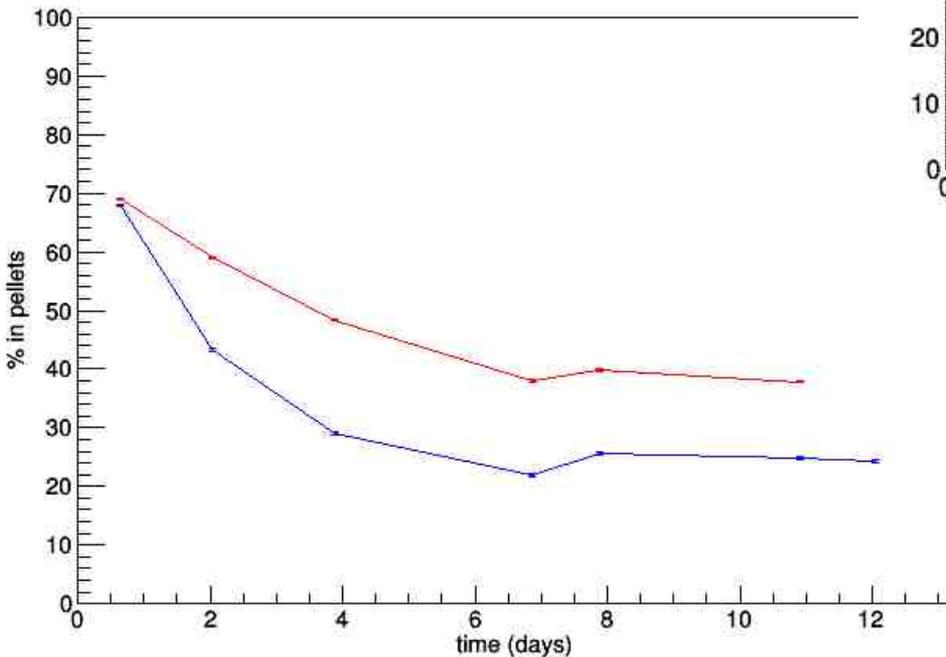
-- Oxidized

Dissolution studies: results

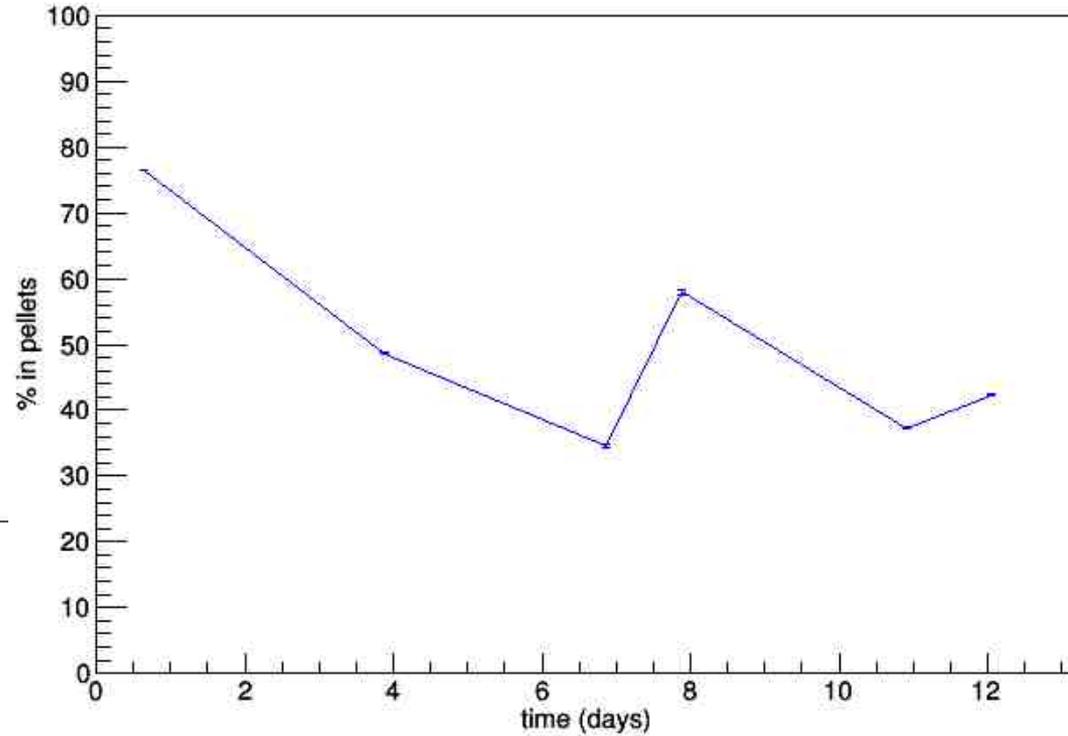
10 mM phosphate buffers with pH = 7.41 & 8.7

-- Fresh
-- Oxidized

pH 7.41



ph 8.7



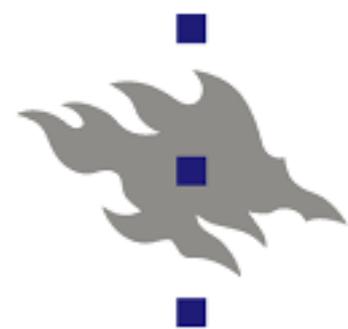
Conclusion & Perspectives

- Development of the experimental protocol for direct implantation
 - coating treatment after implantation will be tested
 - Longer dissolution studies to be planned
- Smaller amount of activity in washed particles - Washing effect is important during the first 24h
- Several particles candidates seems to reach a stabilized level in different pH after few days
 - in pH 5.5 and 7.41 the particles themselves dissolve whereas in pH 2.33 the Cu dissolves from the PSi
 - new stabilization treatments to improve this result.

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Thank you



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